TITLE

Atomic layer deposition (ALD) thin film deposition equipment having cleaning apparatus and cleaning method

PTO-2040 12/99

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		ISSUING C	CLASSIFICATION				
ORIGINAL		CROSS REFERENCE(S)					
CLASS SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)				
NTERNATIONAL	L CLASSIFICATION						
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 			Continued on Issue Slip Inside File Jacket				

TERMINAL DISCLAIMER		DRAWINGS	CLAIMS ALLOWED		
DIOULAIMEN	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
The term of this patent subsequent to (date)				NOTICE OF ALLOWANCE MAILED	
has been disclaimed.	(Assistant Examiner) (Date)				
The term of this patent shall not extend beyond the expiration date					
of U.S Patent. No		•		ISSUE FEE	
				Amount Due	Date Paid
	(Primary E)	(aminer)	(Date)		
The terminalmonths of this patent have been disclaimed.				ISSUE BATCH NUMBER	
	(Legal Instruments Examiner)		(Date)		
WARNING: The Information disclosed herein may be restressed to the Possession outside the U.S. Patent & Tradema	icted. Unauthorized di	sclosure may be propagation	ohibited by the Un	ited States Code Title 35.	. Sections 122, 181 and 368.
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